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## 1 **Supplementary information to:**

2 An Automated Microreactor for Semi-Continuous Biosensor Measurements

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20 **Figures S1-S5** 

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23 Figure S1: Microfluidic chip fabrication and assembly. a Microfabrication of the flow 24 layer silicon mold (reactor, flow channel, filters and measurement zone). In a first 25 step, the AZ1512 resist is deposited on the silicon wafer at the sites where microfilters have to form, which is next etched to lower the overall surface depth. b 26 AZ9260 resist is deposited at the sites of formation of flow channels, measurement 27 zone and reactor, which is baked to form slightly rounded surface structures. A thin 28 layer (30  $\mu$ m) of PDMS is poured by spin-coating to obtain a positive imprint. **c** On a 29 separate Si wafer the AZ1512 resist is placed at the sites where valves and valve flow 30 31 channels will appear. The wafer is next dry etched and PDMS is poured, providing the 32 positive imprint of the valve control layer. **d** A block encompassing the biochip is cut out, peeled off from the mold and aligned with the thin PDMS layer on the other wafer. 33 Bonding and curing attaches both PDMS layers permanently (up to 2.5 bar 34

overpressure). e The complete PDMS biochip block is now cut and peeled from
bottom layer mold, entry holes are punched and the structure is mount and bonded
to a microscope glass slide.

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Figure S2: Set-up of the microfluidic reactor for constant growth and biosensor 41 monitoring. a Sterile solutions and samples are connected to the respective inlets, 42 and are driven by air-control overflow (0.3-0.5 bar air pressure). Other in- and 43 outlets (apart from the cell inlet) are connected to 1 cm open tubes filled with 10 µl 44 H<sub>2</sub>O in order to avoid evaporation of liquid and formation of air bubbles in the 45 channels. **b** A system of solenoid valves joined to pressurized air, which are 46 47 connected by Teflon tubes and bent stainless-steel metal connectors to the biochip, controls the air pressure in the valves. The solenoid valves are operated by a LabView 48 custom program. c Final set-up of the biochip reactor on a glass slide under an 49 inverted epifluorescence microscope for continuous growth and measurements of 50

- 51 biosensor fluorescence. Visible are the stainless-steel adapters inserted in the biochip
- 52 inlets.



Figure S3: Operation principle of the microfluidic chip. a All control valves are open
(indicated in green) and nutrient solution is allowed to wet all channels and inlets.
Subsequently, the valves are closed by applying a pressure of 1.3 bar. b Cells are
inoculated into the nl-reactor via the cell inlet under a driving pressure of 0.3 bar by

opening the valves indicated in green for a few seconds. Afterwards, the valve 59 controlling the cell inlet channel is closed (indicated in dark blue). c Continuous 60 61 culturing is started by simultaneously opening and closing the valves around the nlreactor (driving pressure of 0.5 bar, opening frequency  $15 \text{ h}^{-1}$ , opening time 120 ms), 62 and maintaining the valve to the waste outlet open. Cells flushed from the reactor are 63 collected in the waste outlet. **d** For measurements, the valve to the cell waste outlet is 64 65 closed, the valve in the middle channel is opened, and the nl-reactor valves continue to open and close but under an alternate regime (driving pressure of 0.4 bar, opening 66 frequency 20 min<sup>-1</sup>, opening time 120 ms). Outflowing cells are accumulated against 67 the filter in the measurement zone. **e** As soon as sufficient cells are trapped, the 68 middle valve is closed and continuous growth is resumed in the nl-reactor using the 69 original flow settings. Captured cells are exposed to the sample during 180 min, by 70 opening the sample inlet under a driving pressure of 0.4 bar. The fluorescence signal 71 of the cells is recorded every 30 min. f After the measurement, the cage and channels 72 are cleaned to remove accumulating cells by opening the cleaning inlet, middle valve 73 and valve to the waste outlet (P = 0.5 bar) while closing the nl-reactor in- and outlets. 74 After the cleaning, the system is operated by changing to step **c**. Before each 75 subsequent measurement, step f is repeated, and the complete cycle in constant 76 operation looks like: c, f, d, e, f, c, f, d, e, f, etc. 77

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Figure S4: Scheme of the 13 nl reactor chip and the alternative measurement 82 chamber. a 13 nl reactor layout with flow lines (in grey) and valve control (blue). For 83 84 dimensions, see Figure 1. **b** Cell cleaning from the 13 nl reactor design proceeded by using 0.7 bar overpressure on the measurement cage, by which the filter lines deflect 85 and let the cells pass. Pictures show the cage before cleaning (phase contrast image at 86 200x magnification with accumulated cells), and after cleaning. Because of the 87 difficulties of precise manufacturing of filter line heights, this design was abandoned 88 for a more robust one with back-flushing (see Fig. 1 and S3). 89

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Figure S5. Effect of Triton X-100 on inducibility of the *E. coli* 1598 (pPR-ArsR\_ABS) arsenic bactosensor. Cells were cultured in growth media with or without different Triton X-100 concentrations (w/v) to a culture turbidity of 1.3, washed and resuspended in induction medium (*Online Experimental Methods*). Data are averages from triplicate assays, normalized by the culture turbidity in the assay.

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101 Figure S6. Physiology and induction of GFP fluorescence from *E. coli* 4224 carrying the growth-regulated *rrnB1* ribosomal promoter fusion to a *gfpASV* reporter 102 (unstable GFP variant). a Cell counts by flow cytometry during growth in nutrient 103 solution (Online Experimental Methods) at 37°C of E. coli 4224 in comparison to E. coli 104 105 1598 (pPR-ArsR\_ABS) and *E. coli* with the empty vector pPR-*gfpASV*. **b** Mean 106 fluorescence signal of *E. coli* 4224 cells at culture time points of the experiment in (a), 107 showing activity of the promoter in exponentially growing but not stationary phase cells. c Reactor images of GFP fluorescence (scaled to same maximal intensity) at 108

109 different time points during a 4 day culturing of *E. coli* 4224 in the 13 nl reactor 110 (D~0.28 h<sup>-1</sup>). Circles at 96 h indicate the positions measured for GFP fluorescence in 111 all reactor images for panel (d). **d** Mean reactor fluorescence of *E. coli* 4224 over time 112 in the 13 nl reactor. Stabilization phase, start of continuous culturing; white zones, 113 constant culturing; feed stop, no fresh nutrients.



Video S1 (still image): Actively growing E. coli 1598 cells in the 50 nl reactor. Left side 115 shows the entry filter channels where the fresh nutrients are coming in. Middle 116 "circle" shows a support pillar in the reactor. The video shows a 120 ms valve 117 118 opening (at  $\sim$ 14 s in the movie) after which the cells are pushed back and then swim 119 again in the direction of the filters. Note that some cells enter the filters despite the 120 shallow height (estimated 600 nm), and in some cases even escape through the filters 121 altogether. Because of the strong pressure difference upon nutrient entry, most cell 122 growth remain in the reactor.

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